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Superconductivity in the ternary intermetallics of La₃Ni₄X₄ (X = Si and Ge)

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Abstract

Superconductivity in the ternary intermetallics of La₃Ni₄X₄ (X = Si and Ge) with the combination of AlB₂ and BaAl₄ layers is reported. Both compounds are type II superconductors with critical temperatures (T_c) of 1.0 and 0.70 K for X = Si and Ge, respectively. The lower and the upper critical fields ($H_{c1}(0)$ and $H_{c2}(0)$) for X = Si are 107 Oe and 16.5 kOe, whereas those for X = Ge are 68 Oe and 2.6 kOe, respectively. The gradient $-dH_{c2}/dT$ of La₃Ni₄Si₄ is extraordinarily higher than those of the other three analogues of La₃Ni₄Ge₄ and La₃Pd₄X₄. The magnetic penetration depth ($\lambda(0)$) of 202 nm and Ginzburg–Landau coherence length ($\xi(0)$) of 14 nm are derived for X = Si, while they are 206 and 36 nm for X = Ge.

1. Introduction

Among ternary intermetallic compounds, $\text{Th}\text{Cr}_2\text{Si}_2$ -type intermetallics, RET_2X_2 (RE = rare earth, T = transition metal, X = Si and Ge), have been extensively studied, especially for the interest of the superconducting and magnetic properties. The structure of Th Cr_2Si_2 is the ordered ternary derivative of the binary BaAl₄-type structure [1]. Although superconductivity is observed for some compounds, the critical temperature (T_c) is very low, as observed for, e.g., LaPd₂Ge₂ with a T_c of 1.12 K [2]. Many works were carried out for the discovery of new intermetallic superconductors with higher T_c s. Finally, quaternary intermetallic superconductors RET₂B₂C with Th Cr_2Si_2 -derivative structure showing high T_c s were discovered [3–6]. Among these compounds, YPd₂B₂C shows a T_c of 23 K, which is the highest among Th Cr_2Si_2 -type intermetallic compounds.

Apart from ThCr₂Si₂-type structure, another intermetallic superconductor, MgB₂, was discovered several years ago [7]. The MgB₂ shows a T_c as high as 39 K, which is the highest among intermetallic compounds. The structure of the MgB₂ is AlB₂-type structure, which is composed of alternating of hexagonal layers of Al atoms and graphite-like honeycomb layers of B atoms. Many works have been done so far on

the compounds with AlB_2 -type structure after the discovery of MgB_2 , and several superconductors with this structure have been reported [8, 9].

We have recently reported that La₃Pd₄X₄ (X = Si and Ge) is type II superconductors with T_{c} s of 2.15 and 2.75 K for X = Si and Ge, respectively [10–13]. The crystal structure of La₃Pd₄X₄ is a U₃Ni₄Si₄-type one with the space group of *Immm*, consisting of the combination of structural units of AlB₂-type and BaAl₄-type layers. On the other hand, the other analog intermetallics La₃Ni₄X₄ (X = Si and Ge) do not show superconductivity above 1.8 K [11]. In this paper we report superconductivity in these two compounds below this temperature.

2. Experimental details

Starting materials were La (chunk, 99.9% in purity), Ni (sheet, 99.99%), Si (granule, 99.999%) and Ge (granule, 99.999%). They were arc melted with a stoichiometric ratio of La₃Ni₄X₄ (X = Si and Ge) under Ar gas atmosphere on a water-cooler copper hearth. The melting was repeated several times with the button turned over between each melt. The weight loss was less than 1%. After melting, the obtained buttons wrapped in a Zr foil were annealed in an evacuated silica tube at temperatures between 1173 and 1273 K for one week.

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Figure 1. XRD patterns of $La_3Ni_4X_4$ (X = (a) Si and (b) Ge) samples. The indices shown in the figure are for the $La_3Ni_4X_4$ phase. The XRD peaks assigned to the corresponding $LaNi_2X_2$ phases are marked by full circles.

Samples of $LaNi_2X_2$ (X = Si and Ge) were also arc melted with a stoichiometric ratio of each material, and subsequently annealed in an evacuated silica tube at 1173 K for one week.

Phase identification was carried out for crushed samples by an x-ray diffraction (XRD) method with an x-ray diffractometer JEOL JDX-3500 with Cu K_{α} radiation. Microstructural observation was carried out using a scanning electron microscope (SEM) JEOL JSM-6301F with an energy dispersive x-ray (EDX) spectrometer.

Magnetization measurements were performed for polished polycrystalline samples by a micro-Hall probe technique, with a Hall probe fabricated from two-dimensional electron gas of GaAs/AlGaAs heterostructure. The active area of the Hall probe is $30 \times 30 \ \mu m^2$ with available sensitivity of about 10 mG. Magnetic induction perpendicular to the Hall probe (B_z) is given by measuring the field-linear Hall resistance appearing across the active area. Subtracting an applied field (H_a) from the magnetic induction (B_z) , the magnetization $4\pi M_l =$ $B_z - H_a$ is obtained for a local area of the magnetic material. Field- and temperature-dependent magnetization curves were recorded at temperatures above 0.35 K in magnetic fields up to 500 Oe. The T_c was defined as the onset temperature where a diamagnetic signal was observed. The first penetration field $(H_{\rm fp})$ is proportional to lower critical field $(H_{\rm c1})$ [14]:

$$H_{\rm fp}/H_{\rm c1} = \tanh\sqrt{0.36b/a}$$

where *a* and *b* represent sample lengths perpendicular and parallel to H_a , respectively. The samples in the present experiments were prepared so as to have the dimensions of $a \approx b$, leading to the field ratio $H_{\rm fp}/H_{\rm c1}.0.5$. The $H_{\rm fp}(T)$ was taken as the first deviation point of the $4\pi M_l(H_a)$ curves from the linear Meissner slopes observed in the low-field region.



Figure 2. Temperature dependence of local magnetization curves in an applied field H_a of 5 Oe for La₃Ni₄X₄ (X = Si and Ge).

The magnetization is measured locally by this method, and hence, we investigated a few pieces of the samples to check reproducibility.

Electrical resistivity (ρ) measurements were carried out for a few pieces of each sample in the temperature range from 0.3 to 300 K in magnetic fields up to 11 kOe by a standard DC four-probe method. Upper critical fields (H_{c2}^{on} and H_{c2}^{off}) were estimated, taking account of 10 and 90 % decreases in ρ at superconducting transition of the $\rho(T)$ curves, respectively.

3. Results and discussion

XRD patterns of La₃Ni₄X₄ samples are shown in figures 1(a) and (b) for X = Si and Ge, respectively. The XRD analyses indicate that La₃Ni₄X₄ phases are present as a major phase with a small amount of impurity phases LaNi₂X₂ as reported previously [11]. The content of LaNi₂X₂ is estimated to be about several per cents for both samples. The lattice parameters of La₃Ni₄X₄ are a = 0.41308(5) nm, b = 041760(5) nm and c = 2.3578(3) nm for X = Si, and a = 0.42017(2) nm, b = 0.42167(3) nm and c = 2.4031(1) nm for X = Ge. On the other hand, for LaNi₂X₂ samples, all the peaks in the corresponding XRD patterns are indexed on the basis of bodycentered lattice with space group of I4/mmm, indicating that the samples are obtained as a single phase.

Figure 2 shows temperature dependence of magnetization curves in an H_a of 5 Oe for La₃Ni₄X₄. The T_cs are 1.0 and 0.70 K for X = Si and Ge, respectively. They are almost equal to the zero resistance temperatures, as mentioned below. Figure 3 shows magnetization hysteresis curves of La₃Ni₄X₄ for X = Si and Ge at 0.35 K, respectively. These hysteresis curves indicate that both compounds are type II superconductors. The initial linear Meissner slopes for both samples roughly corresponds to $-1/4\pi$, indicating the almost perfect shielding of these samples.

 H_{c1} was estimated from the magnetization hysteresis curves measured at various temperatures. Figure 4 shows the $H_{c1}(T)$ curves fitted with the formula $H_{c1} = H_{c1}(0)[1 - (T/T_c)^2]$. These fittings result in $H_{c1}(0) = 107$ and 68 Oe for



Figure 3. Magnetization hysteresis curves of $La_3Ni_4X_4$ (X = Si and Ge) measured at 0.35 K.



Figure 4. Lower critical field H_{c1} as a function of temperature for La₃Ni₄X₄ (X = Si and Ge). The H_{c1} data are fitted with the formula $H_{c1} = H_{c1}(0)[1 - (T/T_c)^2]$.

 $La_3Ni_4Si_4$ and $La_3Ni_4Ge_4$, respectively. They are higher than those of the analogues $La_3Pd_4X_4$, whereas much lower than that of intermetallic Ni-based borocarbide superconductors (around 800 Oe) [15] and MgB₂ (around 400 Oe) [16].

Figure 5 shows $\rho(T)$ curves for La₃Ni₄X₄. Both samples show zero resistance at low temperature. The details of the region in the vicinity of T_c are shown in the inset. The resistivity decreases with decreasing temperature, showing metallic-type conductivity with a small negative curvature from 300 to 30 K for both samples. The onset temperature of the resistivity transition is 1.2 K, and zero resistance is observed at 1.0 K for La₃Ni₄Si₄. On the other hand, La₃Ni₄Ge₄ shows the onset temperature of 0.83 K and zero resistance at 0.73 K.

As mentioned above, XRD analyses indicate that the La₃Ni₄X₄ samples contain a small amount of the corresponding LaNi₂X₂ as a major impurity phase. This phase might be responsible for superconductivity in the samples of La₃Ni₄X₄. However, the measurements of $\rho(T)$ curves



Figure 5. Temperature-dependent electrical resistivity ρ for La₃Ni₄X₄ (X = Si and Ge). The insets show the detail of the region in the vicinity of T_c .

for the LaNi₂X₂ revealed that neither of them shows any drop of resistivity above 0.3 K. Therefore, with the almost perfect shielding of the La₃Ni₄X₄ samples in the magnetization measurements as mentioned above, the superconductivity observed for the La₃Ni₄X₄ samples is due to the corresponding La₃Ni₄X₄ phase.

Figures 6(a) and (b) show the $\rho(T)$ curves in various magnetic fields for La3Ni4Si4 and La3Ni4Ge4, respectively. Superconductivity is suppressed by applying the magnetic fields. With increasing the fields, the transition of the $\rho(T)$ curves becomes broader. This is much more appreciable and brings about the large difference between H_{c2}^{on} and H_{c2}^{off} for La₃Ni₄Si₄. Figure 7 shows H_{c2}^{on} and H_{c2}^{off} as a function of temperature for La₃Ni₄X₄. The $H_{c2}^{on}(T)$ curve of La₃Ni₄Si₄ shows a positive curvature in the vicinity of T_c , similar to other superconductors, such as borocarbides [15] and Li₂Pd₃B [17]. Enlargement of the $H_{c2}^{on}(T)$ curve of La₃Ni₄Ge₄ also reveals such a positive curvature in the vicinity of T_c . Except for this region, the gradients $-dH_{c2}^{on}/dT$ are estimated to be 17.0 and 5.3 kOe K⁻¹ for X = Si and Ge, respectively. The gradient $-dH_{c2}^{on}/dT$ for La₃Ni₄Si₄ is much larger than that of La₃Ni₄Ge₄. On the other hand, the difference of the gradient $-dH_{c2}^{off}/dT$ between these compounds is smaller, and the gradients are 6.7 and 3.9 kOe K^{-1} for X = Si and Ge, respectively. Linear extrapolation of the $H_{c2}^{on}(T)$ curves gives a large $H_{c2}^{on}(0)$ value of 16.5 kOe for X = Si, whereas the extrapolation gives $H_{c2}^{on}(0) = 4.0$ kOe for X = Ge. Assuming the Werthamer-Hefland-Hohenberg (WHH) formula $H_{c2}(0)^{WHH} = -0.69T_{c}(dH_{c2}/dT)_{T_{c}}$ [18, 19], $H_{c2}(0)^{WHH}$ of 11.7 and 2.6 kOe are obtained for X = Si and Ge, respectively, using dH_{c2}^{on}/dT as dH_{c2}/dT . For La₃Ni₄Si₄, upturn of the $H_{c2}^{on}(T)$ curve is observed, and the corresponding $H_{c2}(0)^{WHH}$ seems far deviated from $H_{c2}^{on}(0)$ deduced from the observed $H_{c2}^{on}(T)$ curve. In the following calculations, $H_{c2}(0)$ obtained by the linear extrapolation of the $H_{c2}^{on}(T)$ curves was used for La₃Ni₄Si₄ to avoid an inappropriate estimation due to the largely deviated $H_{c2}(0)^{WHH}$. On the other hand, the $H_{c2}(0)^{WHH}$ value for La₃Ni₄Ge₄ is applicable for $H_{c2}(0)$.



Figure 6. $\rho(T)$ curves in various magnetic fields for (a) La₃Ni₄Si₄ and (b) La₃Ni₄Ge₄. The fields were changed stepwise from 0 to 11 kOe by 1 kOe for (a), and from 0 to 2.5 kOe by 250 Oe for (b).



Figure 7. Upper critical fields $(H_{c2}^{on} \text{ and } H_{c2}^{off})$ as a function of temperature for La₃Ni₄X₄ (X = Si and Ge). The H_{c2}^{on} and H_{c2}^{off} were estimated, taking account of 10 and 90% decrease in ρ at superconducting transition of the $\rho(T)$ curves, respectively. Solid and open circles represent H_{c2}^{on} and H_{c2}^{off} for La₃Ni₄Si₄, respectively, whereas the corresponding triangles represent H_{c2}^{on} and H_{c2}^{off} for La₃Ni₄Ge₄. The H_{c2} values at 0 K for both compounds are calculated from WHH theory using dH_{c2}^{on}/dT as dH_{c2}/dT .

With the formula $H_{c2}(0) = \Phi_0/2\pi\xi(0)^2$ (Φ_0 is the flux quantum), the Ginzburg–Landau coherence lengths $\xi(0)$ are calculated. The $\xi(0)$ are estimated to be 14 and 36 nm for X = Si and Ge, respectively. The $\xi(0)$ value of La₃Ni₄Ge₄ is comparable to the value of 38 nm for La₃Pd₄Si₄ [11] and that of 33 nm for La₃Pd₄Ge₄ [10]. These $\xi(0)$ values of La₃Ni₄Ge₄ and La₃Pd₄X₄ are several times larger than those of borocarbide superconductors [5, 15] and MgB₂ [16]. From $H_{c2}(0)$ and $\xi(0)$, the magnetic penetration depths $\lambda(0)$ are calculated to be 202 and 206 nm for X = Si and Ge, respectively, with the formula $H_{c1}(0) = (\Phi_0/4\pi\lambda^2) \ln(\lambda/\xi)$. These values are comparable to that of La₃Pd₄Ge₄ with 248 nm. The Ginzburg–Landau parameters ($\kappa(0)$) are 14.3 and 5.8 for X = Si and Ge, respectively, derived from the formula $\kappa(0) = \lambda(0)/\xi(0)$. On the other hand, thermodynamic critical fields $(H_c(0))$ are 816 and 314 Oe, with the formula of $H_c(0) = H_{c2}(0)/\sqrt{2\kappa}(0)$. Table 1 lists measured and derived superconducting parameters for La₃M₄X₄ (M = Ni and Pd; X = Si and Ge) [10, 11].

The high $-dH_{c2}^{on}/dT$ values are observed for La₃Ni₄X₄, compared with the analogues La₃Pd₄X₄. This is more appreciable for La₃Ni₄Si₄. Possible large anisotropy in $H_{c2}(0)$ originated in crystal structure with a large c/a(b) ratio can bring about such enhancement, if aligned microstructure of crystals was present in the La₃Ni₄Si₄ samples. However, it is unlikely that such aligned microstructure was observed only for all the pieces of the La₃Ni₄Si₄ samples for the resistivity measurements.

On the other hand, the broad transition in the magnetic fields is observed and the enhancement of the gradient $-dH_{c2}^{off}/dT$ is less appreciable for La₃Ni₄Si₄, as shown in figures 6(a) and 7. This might imply the coexistence of a small amount of another La-Ni-Si superconducting phase in the La₃Ni₄Si₄ samples, e.g., such as LaNiSi with a T_c of 1.26 K [20]. Contribution of such a small amount of superconducting phase to the magnetization signals can be negligible. Moreover, specific heat measurements of the La₃Ni₄Si₄ samples revealed that the bulk T_c is 1.0 K and that no trace of other superconducting materials is present in the samples [21]. The onset critical temperature (T_c^{on}) and the thermodynamic critical temperature considering the entropy balance (T_c^{th}) estimated from the specific heat measurements are 1.00 and 0.96 K for La₃Ni₄Si₄, respectively. On the other hand, they are 0.76 and 0.74 K for La₃Ni₄Ge₄. They are in agreement with the results of the magnetization and electrical resistivity measurements. Therefore, we can conclude that La3Ni4Si4 phase is at least a type II superconductor with a $T_{\rm c}$ of 1.0 K from figures 2 and 3. Although a very small amount of possible secondary superconducting phase can bring about a drop of resistivity, the extraordinarily high $H_{c2}(0)$, or $-dH_{c2}^{on}/dT$, observed for La₃Ni₄Si₄ may suggest two-gap nature of the superconductivity in this compound [22]. These possibilities of the coexistence of another superconducting phase or the two-gap nature can also bring about the large

Table 1. Measured and derived superconducting parameters for $La_3M_4X_4$ (M = Ni and Pd; X = Si and Ge) [10, 11].

	La ₃ Ni ₄ Si ₄	La ₃ Ni ₄ Ge ₄	La ₃ Pd ₄ Si ₄ [11]	La ₃ Pd ₄ Ge ₄ [10]
$T_{\rm c}$ (K)	1.0	0.70	2.15	2.75
$H_{\rm c}(0)$ (Oe)	816	314	157	280
$H_{c1}(0)$ (Oe)	107	68	28	54
$H_{c2}(0)$ (kOe)	16.5 ^a	2.6 ^b	2.2 ^b	3.0 ^b
$-dH_{c2}^{on}/dT$ (kOe K ⁻¹)	17.0	5.3	1.5 ^c	1.6 ^c
$\lambda(0)$ (nm)	202	206	376	248
$\xi(0) (nm)$	14	36	38	33
$\kappa(0)$	14.3	5.8	9.9	7.5

^a $H_{c2}(0)$ were estimated by the linear extrapolation of the $H_{c2}^{on}(T)$ curves shown in figure 7.

^b $H_{c2}(0)$ were estimated by the linear extrapolation of the $H_{c2}^{on}(T)$ curves from the WHH theory.

^c The gradient $-dH_{c2}/dT$ was estimated from magnetization measurements.

difference between $H_{c1}(T)$ and $H_{c2}(T)$ in behavior for this compound. The $H_{c1}(T)$ curve of La₃Ni₄Si₄ shown in figure 4 is not extraordinary, compared with those of the other analogues, La₃Ni₄Ge₄ and La₃Pd₄X₄. For further discussions, studies using single crystalline samples are required.

4. Conclusion

The ternary intermetallics of $La_3Ni_4X_4$ (X = Si and Ge) with U₃Ni₄Si₄-type structure with the combination of structural units of AlB₂-type and BaAl₄-type layers are type II superconductors. The T_c s are 1.0 and 0.70 K for X = Si and Ge, respectively. They are lower than those of the analog compounds La₃Pd₄Si₄ (2.15 K) and La₃Pd₄Ge₄ (2.75 K). The BaAl₄ (ThCr₂Si₂)-type LaNi₂X₂, one of the layers in La₃Ni₄X₄, do not show superconductivity above 0.3 K for both Si and Ge. $H_{c1}(0)$ are 107 and 68 Oe for La₃Ni₄Si₄ and La₃Ni₄Ge₄, respectively. The $H_{c2}(0)$ estimated by linear extrapolation is 16.5 kOe for La₃Ni₄Si₄, whereas the $H_{c2}(0)$ estimated by WHH theory is 2.6 kOe for La₃Ni₄Ge₄. The gradient $-dH_{c2}/dT$ of La₃Ni₄Si₄ is extraordinarily higher than the other three analogues of La₃Ni₄Ge₄ and La₃Pd₄X₄. A very small amount of another superconducting phase with high H_{c2} which might be present in the La₃Ni₄Si₄ samples may contribute to superconducting transition and increase the $H_{c2}(0)$ value. Studies using single crystalline samples are awaited.

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